IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Applicant

: Tiow Seng Tan, et al.

Application No.

: 10/566,858

Filed

: January 31, 2006

Title

: TRAPEZOIDAL SHADOW MAPS

Grp./Div.

: 2245

Examiner

: To be determined

Docket No.

: 57090/C982

INFORMATION DISCLOSURE STATEMENT 37 CFR § 1.97(b)

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 Post Office Box 7068 Pasadena, CA 91109-7068 June 28, 2006

Commissioner:

In compliance with the duty of disclosure under 37 CFR §§ 1.56, 1.97 and 1.98, and in accordance with the provisions in the Manual of Patent Examining Procedure §§ 609 and 707.05(b), enclosed is FORM PTO/SB/08A/B listing the references that are known to applicant. Copies of each of the listed Foreign Patent and Other Documents are enclosed. This filing is timely because it is made during one of the periods described in 37 CFR § 1.97(b).

It is respectfully requested that the listed references be considered in the examination of this application and identified on the list of references cited on the patent issuing for this application. Applicant also requests that an initialed copy of FORM PTO/SB/08A/B be entered in the application file and returned to applicant with the next communication from the Office in accordance with MPEP § 609.

Respectfully submitted,

CHRISTIE, PARKER & HALE, LLP

y D. Bruce Prout Reg. No. 20,958

626/795-9900

DBP/dg

Enclosures: Form PTO/SB/08A/B, w/references

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FORM PTO/SB/08A/B (10-01) Substitute for PTO-1449A/B	Attorney Docket Number	57090/C982
INFORMATION DISCLOSURE	Application Number	10/556,858
STATEMENT BY APPLICANT	Filing Date	January 31, 2006
	Applicant(s)	Tiow Seng Tan, et al.
(use as many sheets as necessary)	Group Art Unit	2245
	Examiner Name	To be determined

	U.S. PATENT DOCUMENTS				
EXAMINER INITIALS	Cite No. ¹	DOCUMENT NUMBER Number - Kind Code ² (If Known)	Publication Date MM-DD-YYYY	Name of Patentee	
		6,252,608 B1	06-26-2001	Snyder et al.	
		6,437,782	08-20-2002	Pieragostini et al.	
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EXAMINER INITIALS	Cite No. ¹	FOREIGN PATENT DOCUMENT Country Code ³ - Number ⁴ - Kind Code ⁵ (If Known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	(⋄)
		EP 1 073 016 A1	01-31-2001	Sawa et al.	
		EP 1 126 415 A2	08-22-2001	Hino et al.	

		OTHER DOCUMENTS
EXAMINER INITIALS	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article, title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.
		Martin, T., et al., Trapezoidal Shadow Maps, April 7, 2003, pp 1-7
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		Brabec, S., et al., Practical Shadow Mapping, Journal of Graphics Tools, 2003, pp 1-9
		Fernando, R., et al., <i>Adaptive Shadow Maps</i> , Proceedings of ACM SIGGRAPH 2001, August 2001, pp 387-390
		Govindaraju, N., et al., <i>Interactive Shadow Generation in Complex Environments</i> , Proceedings of SIGGRAPH 2003, pp 501-510
		Lokovic, T., et al., Deep Shadow Maps, Proceedings of SIGGRAPH 2000, pp 385-392
		Stamminger, M., et al., <i>Perspective Shadow Maps</i> , Proceedings of SIGGRAPH 2002, Vol. 21, No. 3, pp 557-562

EXAMINER	DATE	
SIGNATURE	CONSIDERED	

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. ¹Applicant's unique citation designation number (optional). ²See Kinds Codes of USPTO Patent Documents at www.pto.gov or MPEP 901.4. ³Enter Office that issued the document, by the two-letter code (WIPO standard ST.3). ⁴For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. ⁶Applicant is to place a check mark here if English Language Translation is attached.

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		OTHER DOCUMENTS	
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		Tadamura, K., et al., Rendering Optimal Solar Shadows Using Plural Sunlight Depth Buffers, The Visual Computer, Vol. 17, No. 2, 2001, pp 1-8	
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